

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Patent Application of:

Toshihiko OHASHI et al.

Application No.: 10/541,776

Confirmation No.: 1474

Filed: July 08, 2005

Art Unit: 1794

For: SILICA-CONTAINING LAMINATED
STRUCTURE, AND COATING
COMPOSITION FOR USE IN FORMING A
POROUS SILICA LAYER

Examiner: V. CHANG

REPLY UNDER 37 C.F.R. § 1.114

MS AF

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

INTRODUCTORY COMMENTS

In reply to the Office Action dated December 17, 2009, the following amendments and remarks are respectfully submitted with a Request for Continued Examination (RCE) in connection with the above-identified application.

Remarks begin on page 2.